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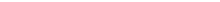
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INFORMATION DISCLOSURE STATEMENT BY APPLICANT <i>(use as many sheets as necessary)</i>				Application Number	09/778490
				Filing Date	February 7, 2001
				First Named Inventor	Pardip K. VAID
				Group Art Unit	3641
				Examiner Name	S. Johnson
Sheet	1	of	1	Attorney Docket Number	5001-355

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Examiner Signature		Date Considered	7/19/2003
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